

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Huilong Zhu, et al.

Examiner: Chuong A. Luu

Serial No: 10/709,239

Art Unit: 2818

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Docket: FIS920030375US1 (17192)

For: STRUCTURES AND METHODS FOR
MANUFACTURING OF DISLOCATION
FREE STRESSED CHANNELS IN BULK
SILICON AND SOI CMOS DEVICES BY
GATE STRESS ENGINEERING WITH
SiGe AND/OR Si:C

Dated: October 26, 2006

Confirmation No: 3238

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

AMENDMENT

Sir:

In connection with filing the above-identified application under 37 C.F.R. §1.53(b), applicants submit the following amendments and remarks for consideration by the Examiner and entry of record in the above-identified patent application.

Amendments to the Claims are reflected in the listing of claims, which begins on page 2 of this paper.

Remarks begin on page 9 of this paper.

CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on October 26, 2006.

Dated: October 26, 2006


Steven Fischman